



李丸

Associate

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Mr. Hwan Lee is currently an associate at Shin & Kim and mainly represents and advises clients in civil and criminal litigation related to intellectual property rights, including patents, utility models, trademarks, copyrights, trade secrets, and unfair competition, as well as litigation and consultation related to personal information and data, administrative appeals.

Mr. Lee passed the 53rd Patent Attorney Examination, graduated from the Department of Electrical and Electronic Engineering at Yonsei University College of Engineering, obtained an LL.M. from Yonsei University Law School, and passed the 11th bar examination.

工作经历

2022-Present Shin & Kim LLC
2016 Passed the Korean Patent Attorney Examination

主要业绩

- Represented a domestic defense contractor and won the case of injunction against patent infringement
- Represented a domestic semiconductor equipment manufacturing company and won the case of injunction against patent infringement
- Represented and won patent infringement and patent invalidation lawsuits related to liquid crystal display optical films
- Represented a domestic telecommunications company and won a patent infringement lawsuit related to the electronic receipt issuing technology

- Represented a domestic furniture company and won a case of injunction against infringement of trademark rights
- Advised on data platform construction project contracts
- Advised a domestic telecommunications company on patent infringement of firewall products
- Advised a domestic game company on privacy policy
- Advised on data crawling business
- Advised a foreign shopping mall company on compliance with the Personal Information Protection Act of Korea

教育背景

2019-2022	Yonsei University Law School (J.D., 2022)
2012-2019	Yonsei University School of Electrical and Electric Engineering (B.S. in Engineering, 2019)

资格

2022	Admitted to bar, Korea
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语言

Korean, English